**TOP PLATE FOR REACTOR FOR MANUFACTURING SEMICONDUCTOR**

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257/697, 695, 748, 786, 773; 361/777; 29/829

See application file for complete search history.

**CLAIM**

The ornamental design for top plate for reactor for manufacturing semiconductor, as shown and described.

**DESCRIPTION**

FIG. 1 is front perspective view of a top plate for reactor for manufacturing semiconductor illustrating our new design;
FIG. 2 is a front view thereof;
FIG. 3 is a rear view thereof;
FIG. 4 is a right side view thereof;
FIG. 5 is a left side view thereof;
FIG. 6 is a top plan view thereof;
FIG. 7 is a bottom view thereof;
FIG. 8 is a reference front view indicating the plane upon which a sectional view is taken; and,
FIG. 9 is a sectional view taken along line 9-9-9 of FIG. 8.

1 Claim, 5 Drawing Sheets